

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:	)	Confirmation No.: 7738
Mitsuhiro ICHIO et al.	)	
Application No. 10/804,053	)	Examiner: Long Pham
Filed: March 19, 2004	)	Group Art Unit: 2814
For: FILM FORMATION METHOD AND	)	Date: March 3, 2008
MANUFACTURING METHOD OF	)	
SEMICONDUCTOR DEVICE	)	

**EX PARTE QUAYLE RESPONSE**

**MAIL STOP AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the *Ex parte* Quayle Office Action mailed January 3, 2008, please amend the above-identified application as follows:

**Amendments to the Claims** begin on page 2 of this paper.

**Remarks** begin on page 9 of this paper.